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Sheet 1 of 1

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INFORMATION DISCLOSURE STATEMENT							Stage of PCT/JP20	
(Use several sheets if necessary)				APPLICANTS  Izumi FUSEGAWA et al.				
·				FILING DATE February 13, 2006				
U.S. PATENT DOCUMENTS								
Examiner Initials	Cite No.	Document Number	Date		Name			
F.H.	1.	2003/0116082 A1	06/26/2003		Masahiro SAKURADA et al.			
FH.	2.	2002/0157600 A1	10/31/2002		Izumi FUSEGAWA et al.			
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Examiner Initials	Cite No.	Document Number	Date		Country		With English Abstract	With English Translation
hH	3.	JP-A-2002-201093	07/16/2002		JAPAN		x	х
_4	4.	WO 01/63027 A1	08/30/2001		WIPO		х	
	5.	WO 01/81661 A1	11/01/2001		WIPO ,		x	
	6.	JP-A-09-202684	08/05/1997		JAPAN		х	х
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V	9.	JP-A-11-147786	06/02/	1999	JAPAN		х	х
FH.	10.	JP-A-2000-327485	11/28/	2000	JAPAN		х	х
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OTHER DOCUMENTS								
Examiner Initials	Cite No.	(Including Author, Title, Date, Pertinent Pages, etc.)						
FH.	11.	Makoto TAKIYAMA et al.; "Dielectric Degradation of Silicon Dioxide Films Cased by Metal Contaminations"; Ultra Clean						
1-4/		Technology; Vol. 5, No. 5/6; Nippon Steel Corporation; pp. 345-359. (with abstract)						
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